Correction to: Research on Design Process of Small Intangible Cultural Heritage Art Gallery Based on VRP-MUSEUM Technology—Taking the Art Gallery of Shanghai Style Lacquerware as an Example

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In the original version of the chapter titled “Research on Design Process of Small Intangible Cultural Heritage Art Gallery Based on VRP-MUSEUM Technology—Taking the Art Gallery of Shanghai Style Lacquerware as an Example”, the given name of the corresponding author and the affiliations of the authors were corrected.

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